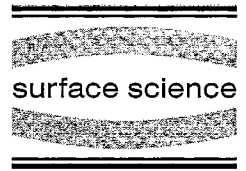




ELSEVIER

Surface Science 364 (1996) 481



Erratum

Erratum to “Growth and structure of Cr ultra-thin film deposited on Co(0001)” [Surface Science 352–354 (1996) 567]☆

P. Ohresser^a, F. Scheurer^{a,*}, B. Carrière^a, J.P. Deville^a, A. Dobroiu^b

^a *Institut de Physique et Chimie des Matériaux de Strasbourg, UMR 046, 23 rue du Loess F-67037, Strasbourg Cedex, France*

^b *Institutul de Fizica Atomica BP MG 6, 76900 Bucuresti-Magurele, Romania*

Received 31 May 1996; accepted for publication 31 May 1996

Several errors have occurred in the text and in Fig. 3:

- (1) Contrary to what can be read in Section 3, the lattice parameter of Cr along the bcc $\langle \bar{1}10 \rangle$ direction is expanded about 6% with respect to bulk Cr in the case of the NW structure (300 K deposition) and 1% in the KS case (470 K deposition). No changes are observed along the $\langle 001 \rangle$ in-plane direction.
- (2) The directions of the hexagonal lattice in Fig. 3 are incorrectly labeled: $\langle \bar{1}2\bar{1}0 \rangle$ should be replaced by $\langle 10\bar{1}0 \rangle$, and $\langle \bar{1}100 \rangle$ should be replaced by $\langle 12\bar{3}0 \rangle$.

☆ SSDI of original article: 0039-6028 (95) 01198-6

* Corresponding author. Fax: +33 88 10 72 48; e-mail: scheurer@morgane.u-strasbg.fr